



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 4981**  
Hiroshi TAKANASHI et al. : **Docket No. 2000-1749**  
Serial No. 09/739,750 : **Group Art Unit 1752**  
Filed December 20, 2000 : **Examiner S. Lee**

**NEGATIVE-WORKING PHOTSENSITIVE RESIN  
COMPOSITION AND PHOTSENSITIVE RESIN  
PLATE USING THE SAME**

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEES FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975

**PETITION FOR EXTENSION OF TIME**

Assistant Commissioner for Patents,  
Washington, DC 20231

Sir:

Petition hereby is made for a third month extension of time to respond to the communication of  
June 19, 2002. *Please note that the two month extension of time fee of \$400.00 was paid on November  
19, 2002.*

The fee of \$520.00 is

(X) submitted herewith.

() to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is  
enclosed.

() Small entity status of this application is established by the verified statement under 37  
CFR 1.9 and 1.27 which

() is enclosed.

() has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

12/20/2002 SFELEKE1 00000016 09739750

02 FC:1253

520.00 OP

By



Matthew Jacob

Registration No.25,154

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December 19, 2002

**RECEIVED**

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